

Serial No.:

Not yet assigned

Filed:

Herewith

For:

WIRING SUBSTRATE, METHOD OF MANUFACTURING THE SAME

AND SEMICONDUCTOR DEVICE

Inventor:

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2) Takashi Kurihara

Atty Doc. No.: 89-01

8/26/0) M. Prifes

INFORMATION DISCLOSURE STATEMENT

Assistant Commissioner for Patents Washington, D.C. 20231

Sir:

In the interest of full disclosure, the following items are herewith identified in Form PTO-1449 and a copy of the same is hereby provided, for the convenience of the U.S. Patent and Trademark Office.

This Information Disclosure Statement is being filed before the mailing date of the first official action.

FOREIGN PATENTS

(AA) JP-5-47842 Miyamoto Toshio, dated February 26, 1993. For relevance see English abstract.

(AB) JP-10-270496 Imasu Seishi, dated October 9, 1998. For relevance see English abstract.

Respectfully submitted,

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INFORMATION DISCLOSURE CITATION					89-01 Not yet assigned					
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